

REF	760-2	6×3mL	EXP	2027-02-15	LOT	488021F	更新日期：	2024-05
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		批号：488021F			
项目\仪器\试剂\方法	单位	均值 \ CV		Lab \ 点数	
(Ag)银					
OTHER Dedicated \ ICP-MS	mg/L	0.013	10%	<5	<100
(Al)铝					
OTHER Dedicated \ ICP-MS	mg/L	0.063	10%	<5	<100
(As)砷					
OTHER Dedicated \ ICP-MS	mg/L	0.012	10%	<5	<100
(Au)金					
OTHER Dedicated \ ICP-MS	μg/L	0.06	9.2%	<5	<100
(B)硼					
OTHER Dedicated \ ICP-MS	mg/L	0.033	10%	<5	<100
(Ba)钡					
OTHER Dedicated \ ICP-MS	mg/L	0.176	10%	<5	<100
(Be)铍					
OTHER Dedicated \ ICP-MS	mg/L	0.001	10%	<5	<100
(Bi)铋					
OTHER Dedicated \ ICP-MS	μg/L	5.83	10%	<5	<100
(Br)溴					
OTHER Dedicated \ ICP-MS	mg/L	0.99	10%	<5	<100
(Ca)钙					
OTHER OTHER \ OTHER	mmol/L	1.08	4.1%	<5	<100
OTHER Dedicated \ ICP-MS	mmol/L	1.4	10%	<5	<100
(Cd)镉					
OTHER OTHER \ OTHER	μmol/L	0.046	4.2%	<5	<100
OTHER OTHER \ OTHER	μg/L	5.13	4.2%	<5	<100
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	μmol/L	0.047	3.8%	<5	<100
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	μg/L	5.24	3.8%	<5	<100
OTHER Dedicated \ ICP-MS	μmol/L	0.055	10%	<5	<100
OTHER Dedicated \ ICP-MS	μg/L	6.16	10%	<5	<100
(Co)钴					
OTHER Dedicated \ ICP-MS	μmol/L	0.009	10%	<5	<100
OTHER Dedicated \ ICP-MS	μg/L	0.55	10%	<5	<100
(Cr)铬					
OTHER Dedicated \ ICP-MS	μg/L	11	10%	<5	<100
(Cs)铯					
OTHER Dedicated \ ICP-MS	mg/L	0.003	10%	<5	<100
(Cu)铜					
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	μmol/L	17.2	12%	<5	<100
BH 5 elements OTHER \ Atomic absorption spectroscopy (AAS)	μmol/L	15.5	7.1%	<5	<100
OTHER OTHER \ Atomic absorption spectroscopy (AAS)	μmol/L	16	6.8%	<5	<100
OTHER Dedicated \ ICP-MS	μmol/L	16.8	10%	<5	<100
(Fe)铁					
OTHER Dedicated \ ICP-MS	μmol/L	6301	10%	<5	<100
(Hg)汞					
OTHER Dedicated \ ICP-MS	μmol/L	0.116	10%	<5	<100
(I)碘					
OTHER Dedicated \ ICP-MS	μg/L	77	10%	<5	<100

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(K)钾					
OTHER Dedicated \ ICP-MS	mmol/L	31	10%	<5	<100
(Li)锂					
OTHER Dedicated \ ICP-MS	mmol/L	0.002	10%	<5	<100
(Mg)镁					
OTHER OTHER \ OTHER	mmol/L	1.12	3.6%	<5	<100
OTHER Dedicated \ ICP-MS	mmol/L	1.86	10%	<5	<100
(Mn)锰					
OTHER Dedicated \ ICP-MS	μg/L	26.4	10%	<5	<100
(Mo)钼					
OTHER Dedicated \ ICP-MS	μg/L	5.5	10%	<5	<100
(Na)钠					
OTHER Dedicated \ ICP-MS	mmol/L	67	10%	<5	<100
(Ni)镍					
OTHER Dedicated \ ICP-MS	μg/L	9.9	10%	<5	<100
(P)磷					
OTHER Dedicated \ ICP-MS	mmol/L	6.4	10%	<5	<100
(Pb)铅					
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	μmol/L	1.6	12.3%	<5	<100
OTHER OTHER \ OTHER	μmol/L	1.71	7.4%	<5	<100
OTHER Dedicated \ ICP-MS	μmol/L	1.75	10%	<5	<100
(Rb)铷					
OTHER Dedicated \ ICP-MS	mg/L	1.65	10%	<5	<100
(S)硫					
OTHER Dedicated \ ICP-MS	mg/L	1100	10%	<5	<100
(Sb)锑					
OTHER Dedicated \ ICP-MS	mg/L	0.026	10%	<5	<100
(Se)硒					
OTHER Dedicated \ ICP-MS	μmol/L	0.196	10%	<5	<100
(Si)硅					
OTHER Dedicated \ ICP-MS	mg/L	0.66	10%	<5	<100
(Sn)锡					
OTHER Dedicated \ ICP-MS	μg/L	4.4	10%	<5	<100
(Sr)锶					
OTHER Dedicated \ ICP-MS	mg/L	0.082	10%	<5	<100
(Ti)铈					
OTHER Dedicated \ ICP-MS	μg/L	3.3	10%	<5	<100
(V)钒					
OTHER Dedicated \ ICP-MS	μg/L	3.3	10%	<5	<100
(Zn)锌					
OTHER EWAI \ Atomic absorption spectroscopy (AAS)	μmol/L	103	6.7%	<5	<100
BH 5 elements OTHER \ Atomic absorption spectroscopy (AAS)	μmol/L	90	4.5%	<5	<100
OTHER OTHER \ Atomic absorption spectroscopy (AAS)	μmol/L	86.4	5.9%	<5	<100
OTHER Dedicated \ ICP-MS	μmol/L	104	10%	<5	<100

注：此报告所提供的数据均基于检测相同批号质控品的若干实验室的数据汇总统计而来，仅供学习、参考之用。因所用技术、仪器和试剂的不同，或因制造商检测方法的改变，均可导致实验室实际测得的数据偏离此报告所提供的数据。根据良好实验室规范的要求，实验室须遵循相关技术规范确立自己的均值和可接受范围。